

### **Abstract of the Disclosure**

This invention relates to a method and a device for CVD coating of a workpiece.

In the method for CVD coating, in particular for aluminizing at least one workpiece, a coating gas which serves to coat the workpiece or each workpiece is created.

According to this invention, the workpieces to be coated are arranged in a coating room, whereby coating granules are arranged near the workpieces to be coated. The coating room together with the workpieces to be coated and together with the coating granules is heated to the process temperature. After reaching the process temperature, a process gas is introduced onto the coating granules, thereby creating coating gas.

(Fig. 1)